Monomeric Base-Stabilized Phosphino- and Arsinoalanes

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Received June 26,1992

Summary: The first base-stabilized phosphino- and arsinoalane monomers, HzAlEMesaNMes (Mes = *mesityl;* 1, $E = P$; 2, $E = As$) have been prepared. Thermolysis *at 95 "C converts 1 to the trimer [H2AlPMesJ3 (3); further heatingat 125 OCresults in the formation of MesgHand aluminum metal.*

In comparison with the aminoboranes $(R_2NBR'_2)_n$ relatively little information is available regarding the chemistry of the heavier group **13/15** analogues such as the phosphinoalanes $(R_2PAIR'_2)_n^1$ and arsinoalanes $(R_2-$ AsAlR'₂)_n.² The few compounds that are known exist as dimers $(n = 2)$ or trimers $(n = 3)$ depending on the steric demands of the substituents. In part, our interest in such compounds stems from the possibility that, like the analogous arsinogallanes, 3 they might serve as single-source precursors to group **13/15** electronic materials. However, one of the drawbacks with the currently available singlesource precursors is low volatility. Two obvious approaches to enhanced volatility are (i) to decrease the degree of oligomerization and (ii) to use less bulky substituents. Herein we report the isolation of the basestabilized monomers H_2 AlEMes₂-NMe₃ (Mes = mesityl; 1, $E = P$; 2, $E = As$). The structure of the phosphorus compound **1** has been determined by X-ray analysis. To our knowledge, this represents the first structural information on a monomeric base-stabilized phosphinoalane. Another noteworthy feature is that **1** undergoes thermal decomposition to afford metallic aluminum rather than aluminum phosphide. This represents an unprecedented mode of thermolysis for compounds of this general type.

Monomers 1 and 2 were prepared in yields of $75-80\%$ via the metathetical reaction of $H_2AICl\cdot NMe_3$ with LiE- $(Mes)_2$ in Et₂O solution at low temperature.⁴ Both compounds are colorless, crystalline solids. In the case of **2,** the proposed molecular formula was established by the presence of a CI-MS peak at *mlz* **402,7** which corresponds to $M + H^+$. For 1, the highest m/z peak was detected at **299,** thus indicating a loss of Me3N. However, the presence of coordinated Me3N in solutions of both **1** and **2** was demonstrated by ${}^{1}H$ and ${}^{13}C$ NMR spectroscopy.⁷ There was no evidence for Me₃N dissociation at ambient temperature. Equal abundances of mesityl and hydride ligands were also clear from ${}^{1}H$ and ${}^{13}C$ NMR spectroscopic data. Only crystals of 1 proved suitable for X-ray analysis.⁸ The solid state of **1** comprises individual molecules (Figure l), and there are no short intermolecular contacts. A donor molecule of Me3N is attached to the aluminum atom of each H₂AlPMes₂ unit, and the Al-N bond distance in 1 (2.009 (8) Å) is slightly shorter than that in H_3 Al-NMe₃ **(2.063** (8) Ah9 The P-A1 bond order in **1** is unity **as** indicated by the fact that this bond distance **(2.409 (3) A)** is only slightly shorter than those observed in Al_2P_2 dimers (range 2.433 (4)-2.475 (1) Å)¹ and virtually identical to

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(7) CI-MS (CH₄): 1, *m/z* 299 (M + H⁺ - Me₃N); **2**, *m/z* 402 (M + H⁺);
3, *m/z* 596 (dimer⁺). ¹H NMR (300.15 MHz, C₆D₆, 295 K): 1, *δ* 1.76 (9H, **s,** NMe3), 2.12 (6H, **s,** 4-Me), 2.63 (12H, **s,** 2,6-Me), 6.80 (4H, **s,** 3,5-H ring), 4.40 (2H, vbr, AlHz); 2, 6 = 1.72 (9H, **s,** NMeS), 2.12 (6H, s,4-Me), 2.60 (12H, **s,** 2,6-Me), 6.78 (4H, **s,** 3,5-H ring), 4.55 (2H, vbr, AlH2); 3, 6 = 1.97 (6H, s, 4-Me), 2.51 (12H, s, 2,6-Me), $\overline{6.60}$ (4H, s, 3,5-H ring), 5.20 (2H, vbr, AlH₂). ¹³C{¹H} NMR (75.48 MHz, 295K, C₆D₆, TMD external standard): 1, $\delta = 20.9$ (s, 4-Me), 24.9 (d, J = 10.3 Hz, 2,6-25.8 **(s,** 2,6-Me), 47.7 **(s,** NMe3), 129.1 *(8,* 3,5-C ring), 135.6 *(8,* 4-C ring), 138.1 *(8,* 1-C ring), 142.9 **(s,** 2,6-C ring); 3, 6 20.7 **(9,** 4-Me), 24.9 (t, *J* = **3.4Hz,2,6-Me),130.4(d,J=3.4Hz,3,5-Cring),139.2(~,4-Cring),139.5** (m, 1-C ring), 144.3 (t, *J* = 4.0 Hz, 2,6-C ring). 31P(1H} NMR (121.5 MHz, 295 K, C₆D₆, 85% H₃PO₄ external standard): 1, $\delta = -97.3$ **(s, br)**; 3, $\delta = -84.9$ **(s, br).** IR (Nujol mulls, NaCl, ν_{A-H} , cm⁻¹): 1, 1810 vs, 1785 vs; 2, 1800 sh, 1790 s; 3, 1840 sh, 1825 vs. Mp: 1, 95 °C dec; 2, 115–118 °C dec;
3, 100 °C dec. Anal. Calcd for 1: C, 70.56; H, 9.31. Found: C, 70.08;
H, 9.17. 2: C, 62.84; H, 8.29. Found: C, 62.62; H, 8.27. Calcd fo 72.47; H, 8.11. Found: C, 72.84; H, 7.72.

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^{(4) 1:} A solution of Mes₂PH⁵ (540 mg, 2.0 mmol) in Et₂O (45 mL) was treated with *n*-BuLi (1.25 mL, 1.6 M, 2.0 mmol) at -78 °C. The resulting yellow solution was allowed to warm to 25 "C, and stirring was continued for an additional 1 h at this temperature. After being cooled to **-78** OC, the LiP(Mes)₂ solution was added dropwise to a solution of H₂AlCl-NMe₃⁶ (250 mg, 2.0 mmol) in Et₂O (30 mL) at -78 °C. The solvent and volatiles were removed under reduced pressure, and the colorless residue was extracted with hexane (50 mL). After filtration and concentration of the filtrate, colorless crystals of 1 formed in 75% yield (mp 122 °C dec). 2: The procedure was similar to that described for 1 except that toluene was The procedure was similar to that described for 1 except that toluene was used for extraction and recrystallization. Yield: 80%. Mp: 115-118 °C dec. 3: A mixture of LiAlH₄ (115 mg, 3.0 mmol) and AlCl₃ (400 mg, 3.0 mmo stirring was continued for an additional 48 h at the latter temperature. The white, cloudy suspension was cooled to -78 °C and treated with 3.0 mmol of LiP(Mes)_2 (see above). After the solution was warmed to 25 °C , the solvent and volatiles were removed under reduced pressure. The the solvent and volatiles were removed under reduced pressure. resulting colorless residue was extracted with toluene (30 mL). After filtration, attempts were made to grow crystals of 3 by storage of concentrated solutions at -40 °C. These attempts were not successful, and 3 was isolated as a colorless powder (mp 80 °C dec) in 50% yield by complete removal of the solvent.

^{(8) 1:} monoclinic, space group $P2_1/c$ (No. 14), $Z = 4$; $\alpha = 17.180$ (5), $b = 8.318$ (2), $c = 16.643$ (6) \mathbf{A} ; $\beta = 114.53$ (2)°; $V = 2163$ (20) \mathbf{A}^3 ; ρ_{caled}
= 1.10 g cm⁻³; $2 < 2\theta < 50$ ° (Mo K α , $\lambda =$ 0.0616 and $R_w = 0.0657$.

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Figure 1. View of the crystal structure of H_2 AlPMes₂. NMe₃ (1). Important bond distances **(A)** and angles (deg) (standard deviations in parentheses) are as follows: $AI-P = 2.409(3)$,
P-C1 = 1.856 (7), P-C10 = 1.862 (7), Al-N = 2.009 (8), Al-H1 $P = 1.598 (7)$, Al-H2 = 1.53 (7); Al-P-Cl = 100.3 (2), Al-P-Cl0
= 110.3 (3), Cl-P-Cl0 = 106.6 (3), P-Al-N = 111.3 (2), N-Al- $H1 = 101 (3)$, N-Al-H2 = 97 (3), P-Al-H1 = 118 (3), P-Al- $H2 = 110$ (3), $H1-A1-H2 = 115$ (4).

that observed in an aluminum-phosphorus cubane.1° Such a view is supported by the observed pyramidality at phosphorus (sum of angles $= 317.2^{\circ}$). Like monomeric phosphinoboranes,¹¹ phosphino- and arsinoalanes are, in principle, capable of multiple bonding. Clearly, however, in the case of **1** such bonding is thwarted by the strong donor action of Me3N and consequent rehybridization at aluminum.

When solid **1** was heated under vacuum at 95 "C for 0.5 h, Me3N was eliminated and a colorless, microcrystalline compound of empirical composition $H_2AIPMes_2$ (3) was

formed⁷ together with $Mes₂PH. Compound 3 can also be$ isolated (50% yield) from the reaction of H_2 AlCl with LiP- $(Mes)₂$ ⁴ The degree of oligomerization of 3 was not clear from mass spectroscopic data since the highest *mlz* peak that was detectable in CI or E1 experiments corresponds to the dimer.'

Peralkylated derivatives of empirical composition R₂- MER'_2 undergo thermolysis via alkene/alkane elimination. As such, they represent attractive single-source precursors to group 13/15 semiconductor materials, ME. Interestingly, compound **1** (and preliminary **2)** undergo thermolysis by a completely different pathway. As pointed out above, heating 1 at 95 °C causes initial loss of Me₃N. Further heating at 125 "C (toluene solution) resultsin the formation

of Mes₂PH as the sole phosphorus-containing product.
H₂AlPMes₂·NMe₃
$$
\rightarrow
$$
 ¹/₃(H₂AlPMes₂)₃ \rightarrow

 $Al + Mes₂PH + ¹/₂H₂$

There is considerable current interest in new aluminum precursors for the microelectronics industry. To date, most of the emphasis has been placed on adducts of the type base-AlH₃.¹² To our knowledge σ -bonded derivatives with A1-H functionalities have not been explored **as** potential aluminum sources. We have succeeded in growing films of aluminum from 3 on Si[100] substrates in a horizontal cold-wall OMCVD reactor. The temperatures of the saturator and deposition zones were 70 and 300 °C, respectively, and the reactor pressure was 1×10^{-3} Torr. The films were characterized by X-ray photoelectron spectroscopy (XPS) after etching with ionized argon. The XPS analysis also indicated traces (350 ppm) of phosphorus.

Acknowledgment. We are grateful to the National Science Foundation (Grants CHE-9007166, CHE-9108228), the Science and Technology Center Program (Grant CHE-08920120), the Robert A. Welch Foundation, and the Army Research Office for generous financial support.

Supplementary Material Available: Tables of positional and thermal parameters and selected bond distances, bond angles, and torsion angles and a figure showing the unit cell of **1** (8 pages). Ordering information is given on any current masthead page.

OM9203845

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